

Feature

Pass Bands: 5GHz ~ 7GHz, 7GHz ~ 9GHz, 9GHz ~ 11GHz, 11GHz ~ 13GHz; Insertion Loss in pass bands: \leq 8.0dB Isolation between pass bands: \geq 30dB Size: 5.0x4.5x0.15mm

Description

This device is a FET switch filter bank MMIC based on GaAs processing. Adopt +5V/0V logic control, switching time is less than 30ns typ. It has low loss, excellent isolation, and high integration.

The metallization processing of thru-holes on the plate ensures good grounding. Extra grounding measures aren't required, which is easy for application. The back metallization is suitable for eutectic sintering or conductive adhesive sticking processes.

Absolute Rating

Control Voltage	-1V~+5.5V
Current at Control port	0.01 mA ~ 0.1mA
Input Power	27dBm
Storage Temperature	-65~+150°C
Operating Temperature	-55~+125℃

Electrical Specifications 1 (T_A=+25°C)

Spec.	Pass band 1	Pass band 2	Unit
Freq. Range	5-7	7-9	GHz
Insertion Loss	≤8.0	≤8.0	dB
Rejection	≥40@3.4&8.6GHz	40@5.4&10.6GHz	dBc
Ripple in BW	≤2		dB
VSWR	≤1.8		—

Electrical Specifications 2 (T_A=+25°C)

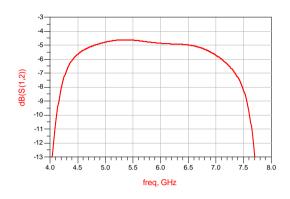
Spec.	Pass band 3	Pass band 4	Unit
Freq. Range	9-11	11-13	GHz
Insertion Loss	≤8.0	≤8.0	dB
Rejection	≥35@7.4&12.6GHz	≥35@9.4&14.6GHz	dBc
Ripple in BW	≤2		dB
VSWR	≤1.8		—

S2P file name: PDSBF4-5/13-5D6.s2p

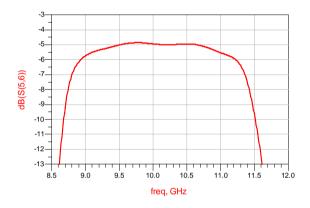


Typical Test Curves

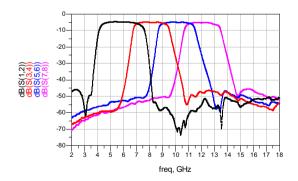
Pass band 1 Insertion Loss VS Frequency ($T_A=25^{\circ}C$)



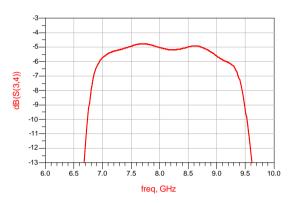
Pass band 3 Insertion Loss VS Frequency ($T_A=25^{\circ}C$)



Insertion Loss VS Frequency (T_A=25°C)



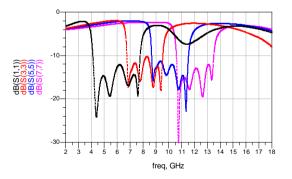
Pass band 2 Insertion Loss VS Frequency (T_A=25°C)



Pass band 4 Insertion Loss VS Frequency (T_A=25°C)

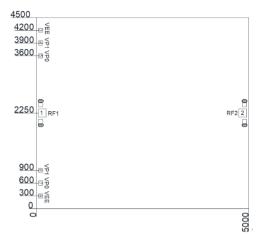








Mechanical Specification



Truth Table

Driver Voltage (VEE=-5V)		
+5/0V Control		Pass bands
VP1	VP0	
0V	0V	5-7GHz
0V	5V	7-9GHz
5V	0V	9-11GHz
5V	5V	11-13GHz

PINS Definitions

Pin No.	Symbol	Description
1, 2 RF1, RF2		RF Input, RF
	Output	
3, 8	VEE	Driver Power
	VEE	Supply Voltage
4, 5, 6, 7		+5/0V
	VP1, VP0	Control ports

Notes:

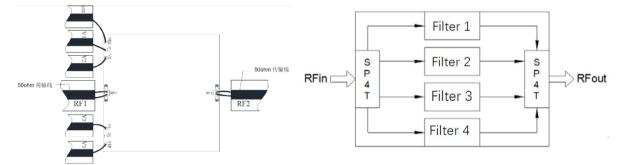
- 1. Dimensions are um. Tolerance: ±0.05mm
- 2. Die thickness is 0.1mm

3. Typical bond pad is 100um $\star 100 \text{um}$, which is 50um away from chip edge.

4. The bottom of the device is gold plated, should be grounded.

Recommended Assembly Diagrams

Functional Diagram



Application Notes:

1. The chip is back-metallized and can be die-mounted with AuSn eutectic preforms or with electrically conductive epoxy.

2. The die should be assembled on carriers like Kovar or Mu-Cu which have same Coefficient of thermal expansion. (5.8×10-6/) with GaAs.

- 3. Recommend using Φ 25um Au wire for bonding, whose length is around 200um.
- 4. Sinter by AuSn (80/20), which doesn't exceed 300°C within 30 seconds max.
- 4. Handle the chips in a clean environment. DO NOT attempt to clean the chip using liquid cleaning systems.
- 5. Handle the chip along the edges with a vacuum collet or with a sharp pair of bent tweezers.
- 6. The device is sensitive to ESD. ESD protection is required during storage and usage.
- 7. If you have any questions, please contact us.